Description of instrumentation and use:

A single piece of equipment was purchased, consisting of a multiple cathode, radio frequency-excited sputter deposition apparatus that is entirely automated. The equipment is custom-made, was designed and built by TM Vacuum Products, Inc., 630 Warrington Avenue, Cinnaminson, NJ. A contact person is Louis Mozdzen at (609) 829-2000 ext 108. A detailed description of the equipment is attached. The equipment does not differ from that described in the original grant proposal.

The equipment is used to fabricate thin film ceramic nanolaminates. These nanolaminates consist of multilayer stacks in which the consistents are usually polycrystalline. Unique mechanical and chemical properties are achieved because of the nanoscale of each bilayer. These properties include transformation-toughening, enhanced hardness, high temperature stability, and corrosion resistance. A related patent entitled "Multilayer Nanolaminates Containing Polycrystalline Zirconia," has been issued (US No. 5,472,795, C.R. "Alita", 12/5/95, name misspelling correction issued 5/17/96). This patent was developed under DoD funding. To date we have used the equipment to
Ongoing research projects for which the instrumentation is used:


3. C.R. Alta, Shared Research Equipment Program Grant, Oak Ridge National Laboratory. "Mechanical Behavior of Ceramic Nanolaminate Coatings." 10/96-9/97, $4,400 (travel funds)+free equipment use at ORNL.

Publications resulting from the above projects:


Invited papers at national/international symposia resulting from the above projects:


INSTRUCTIONS FOR VENDOR

Deliver between 8 A.M. and 3 P.M. No Saturday, Sunday or holiday deliveries.

Accompany this order promptly. Accompany each delivery with a shipping ticket or memo showing Order Number and material furnished.

Our Federal Employer Identification number is 33-6006432W.

If any item(s) on this order is a hazardous chemical, as defined under 29 CFR 1910.1200, provide one copy of Material Safety Data Sheet for each item with the shipped container and one copy with the invoice.

VENDOR - See Other Side for Standard Terms and Conditions of Purchase.

Return rejected low dollar orders to:
UWM Purchasing, P.O. Box 777, Milwaukee, WI 53201

Authorized Institutional Account:

Low Dollar Order/Requisition No.

Send correspondence to attention of the department listed as "ship to" at:
The University of Wisconsin-Milwaukee
P.O. Box 413
Milwaukee, Wisconsin 53201

Send invoices in triplicate to:
UWM Accounts Payable
P.O. Box 966
Milwaukee, Wisconsin 53201
414-229-5404

Requisitioner:

See reverse of last ply and Administrative Services Manual Sections 3.2 & 3.3 for instructions on completion and routing. Low dollar orders cannot exceed department's delegated limits.

FS TR TASK ACCT UNIT DIV DEPT ACT CLASS MGR NO BLDG NO A MOUNT

95/6 144 - FD47 C 19 5900 4 $129,984
95/6 C 34 $129,984

BLANKET ORDER PERIOD:

From: 
To:

DATE

8/23/95

Vendor:

T-M Vacuum Products, Inc.
630 S. Warrington Avenue
Box 2248
Cinnaminson, NJ 08077

Attn: John Strada
Fax: 609/829-0990

University of Wisconsin-Milwaukee

Dr. Carolyn R. Aita (EMS 117)
UWM-CEAS-Materials Department
3200 N. Cramer Street
Milwaukee, WI 53211

Terms:

Reference:

Price

Commodity Code

Unit Price

Total

1 System Automated Sputter Deposition System designed to deposit multi-layer stacks of alternating materials via RF diode sputtering specifically for transformation-toughening Oxide Nano-laminates

$259,968.00

Michael Wiggins

Call: 414-229-4342

TAX EXEMPTIONS

The state of Wisconsin and its agencies are exempt from payment of all federal tax and Wisconsin state and local taxes on its purchases except Wisconsin sales or occupation tax as described on the back of this form. The state of Wisconsin does not have a tax exemption number for state agencies.

Federal Exemption No.: 38-73-1021-K is on file with the Internal Revenue Service, Milwaukee.

Desig: Chairperson

George Baker

Date: 23 Aug 95

Print: White - Vendor
Pink: Official File Copy
Green: Dean

013

Authors...
SPUTTER DEPOSITION SYSTEM
FOR TRANSFORMATION - TOUGHENING
OXIDE NANOLAMINATES

VACUUM CHAMBER

The vacuum vessel is constructed from 304 stainless steel. Chamber diameter is 24" and the chamber measures 14" tall. The chamber base plate contains the following penetrations:

- One (1) 6" pumping port which mates with cryopump.
- One (1) 1 ½" diameter roughing port.
- One (1) 1" compression fitting for hot filament ion gauge tube.
- One (1) ¼ pipe tap for thermocouple gauge tube.
- One (1) Central penetration for substrate table.
- One (1) penetration for admission of process gas.
- One (1) penetration for admission of venting gas.

The top of the chamber is fitted with a 24" diameter sealing flange. This main sealing flange seals the chamber to the removable lid via a Viton O-ring. The chamber side wall contains the following penetrations:

- One (1) shuttered 4" viewport located at the front of the chamber.
- One (1) 4" quartz window to accommodate customer supplied optical emission spectrometer.
- Two (2) 2-3/4 conflat flanges for crystal monitor heads.

The chamber top plate is removable and contains the following penetrations:

- Four (4) 5" diameter holes, two (2) are fitted with sputtering cathodes, one (1) is fitted with a radiant heater and the final hole is blanked for future use.

VACUUM PUMPING

The system is rough pumped by a 20 cfm two stage mechanical pump. High vacuum pumping is provided by a 4000 liter/second (for water) cryopump with water cooled liquid helium compressor.

VACUUM VALVING

All vacuum valves are electropneumatically operated and all vent and gas admission valves are solenoid operated. High vacuum valving is provided by a 6" A.S.A. stainless steel gate valve. A 1 ½" right angle stainless valve provides rough pump valving. A 1" right angle valve provides for pump-out of the cryopump after regeneration. A ½" solenoid valve provides purge gas admission for use during the cryo regeneration process.
VACUUM GAUGING

The dual function vacuum gauge provides both rough vacuum and high vacuum readouts. The rough vacuum portion of the gauge provides readouts for two (2) thermocouple gauge tubes via a dual bar graph display. Each gauge tube has two (2) adjustable set points.

The high vacuum portion of the gauge reads out via a digital display that reads from $10^{-4}$ TORR down to $10^{-6}$ TORR. The high vacuum readouts are taken from a hot filament ion gauge tube.

VACUUM PIPING

The vacuum pumping manifold is constructed from Type K hard copper tubing and is silver soldered into a leak tight rigid assembly.

SYSTEM FRAME

The vacuum chamber and pumps are mounted within a structural steel frame which is covered by removable steel skins.

SUBSTRATE TABLE

A 22" diameter rotating aluminum substrate table is centrally located in the bottom of the chamber. The table rotates via external drive motor between 0-30 rpm. The table is electrically isolated from the chamber and is mounted on a FerroFluidic feedthrough.

SPUTTER SOURCES

Two (2) 5" diameter RF diode cathodes are mounted on the chamber top plate. The power and water connections to the cathodes are external to the sputtering system. Each cathode is fitted with a pneumatically operated shutter, which is primarily used as a deposition catcher during pre-sputtering.
(Cathode cleanup.)

SUBSTRATE HEAT

A 2 KW radiant heater provides for heating of the substrates when necessary. Heating can be accomplished while the substrate table is stationary or rotating. The heater is mounted on the chamber top plate and electrical connections are external to the vacuum.

SPUTTER POWER

Two (2) dedicated RF power supplies (13.56 Mhz) provide sputter power. Each RF supply is rated at 2 KW. Two (2) auto tune networks are provided for the power supplies. Additionally a phase shifter is included. The cathodes can be operated either simultaneously or sequentially without causing RF interference.
PROCESS GAS SYSTEM

A two (2) gas flow control and pressure control system is comprised of the following components:

- Two (2) thermal mass flow controllers, 1 each for argon and oxygen. (please specify flow range).
- One (1) four channel, four gas flow controller electronics unit.
- One (1) high accuracy capacitance manometer (0-100 millitorr range).
- One (1) capacitance manometer electronic control unit.
- One (1) servo controlled, 6" diameter low vane throttle valve.
- One (1) exhaust control valve electronics unit.

DEPOSITION THICKNESS MONITORS

- Two (2) water cooled crystal thickness monitors (one beneath each cathode) are located within the vacuum chamber.
- A single electronics control unit services both crystal monitor heads.
- One or both cathodes can be powered at a given time. Each crystal monitor can be programmed to shut down sputter power from the cathode it is monitoring when the required thickness is reached.

CHAMBER HOIST

The flat chamber lid containing two cathodes, radiant heater and blanked off fourth cathode port is lifted by an air/oil hoist. The lid can travel up to 18" vertically from its sealed position on the chamber. The hoist is operated by a momentary raise/lower switch.

SYSTEM OPERATIONAL MODES

AUTOMATIC MODE

In this mode the operator would load the system with one (1) or more substrates, lower the chamber lid and push the "auto pump" button.

The system will automatically pump from atmosphere to high vacuum. When high vacuum is reached, the operator will initiate the automatic coating cycle by pushing the "process start" button. The system will automatically deposit alternate layers of two (2) reactively sputtered materials. Sputter parameters have been previously established and set. The system will automatically rotate the substrate table. At the end of a predetermined number of deposited layers the system will stop the coating process.

The operator pushes the "system vent" button and the vacuum chamber vents to atmosphere.

- 3 -
MANUAL MODE

In this operational mode the system vacuum valves are actuated by manually pushing lighted valve buttons on the control panel. The deposition portion of the cycle remains the same as described above. In this mode all safety interlocks are active. The operator cannot improperly sequence the vacuum valves.

MAINTENANCE MODE

In this mode, all functions are carried out manually with interlocks disabled.

CAUTION: This is a key locked mode and should only be used by trained maintenance personnel who are intimately familiar with the operation of the system. This mode is usually employed when diagnostic and/or repair procedures are conducted.

AUTO REGEN MODE

The system is equipped with an automatic cryopump regeneration mode. By switching the system to this mode and pushing the AUTO REGEN button, the system will automatically go through a complete cryopump regeneration cycle and return itself to a "READY TO RUN" condition. The AUTO REGEN cycle usually takes a total of about 5-6 hours.

SYSTEM INTERLOCKS

This system is equipped with the following safety interlocks:

- Vacuum interlock: Monitors sequencing of vacuum valves so that valves cannot be opened unless proper pressure conditions exist. Prevents hoist from operating when chamber is under vacuum.
- Electrical interlock: Prevents sputter power from being applied unless chamber is under vacuum.
- Water interlock: Sputtering power and cryo compressor cannot be operated unless water flow is present.
- Compressed air interlock: Vacuum valves and hoist cannot be operated unless compressed air pressure is present.
- Cabinet interlock: High voltage in electrical system will not operate unless all cabinet doors are closed.

UTILITIES REQUIRED

- 208 volt, 3 phase, 60 hz, 100 amp electrical service. 
- Compressed air - 2 cfm @ 90-120 psig.
- Water. 3 gpm at 55° Fahrenheit.

The customer will provide an optical emission spectrometer to be used with the system, and two (2) 5" sputtering targets.
WARRANTY

The system is warranted for one (1) year from date of shipment. Warranty includes parts and labor but does not include consumables such as sputtering targets, pump fluids, and O-rings.

The system is available for $259,968.00 F.O.B., Cinnaminson, NJ

Delivery will be via padded electronics van in 18-20 weeks after receipt of order.

Payment terms are:

- 20% with purchase order.
- 20% upon approval of engineering drawings.
- 20% upon commencement of construction.
- 20% upon acceptance at T-M Vacuum.
- 20% net 30 upon shipment.

John Strada
T-M VACUUM PRODUCTS, INC.
Sales Manager

JS/cam